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## **Supporting information**

Electrolyte	Concentration, M	Voltage, V	n-GaN loss, mol	Charge, C	Z
H <sub>2</sub> SO <sub>4</sub>	$5 \times 10^{-5}$	20	0.0003	203.9	5.99
H <sub>2</sub> SO <sub>4</sub>	0.05	5		111.2	
$H_2SO_4$	0.05	10	0.007	3985.2	6.01
H <sub>2</sub> SO <sub>4</sub>	0.05	15	0.010	5987.1	6.17
$H_2SO_4$	0.05	20	0.016	9842.6	6.24
$H_2SO_4$	0.25	15	0.100	59964.0	6.18
$H_2SO_4$	0.5	20	0.452	263971.2	5.88
Na <sub>2</sub> SO <sub>4</sub>	0.1	5		0.03	
Na <sub>2</sub> SO <sub>4</sub>	0.1	10		46.3	
Na <sub>2</sub> SO <sub>4</sub>	0.1	15	0.0003	172.4	5.73
Na <sub>2</sub> SO <sub>4</sub>	0.1	20	0.001	537.5	6.19
Na <sub>2</sub> SO <sub>4</sub>	1	20	0.088	52642.2	6.17
NaOH	$1 \times 10^{-4}$	20	0.0003	165.0	5.92
NaOH	$1 \times 10^{-3}$	20	0.0123	7173.4	6.08
NaOH	0.1	5	0.001	574.6	5.81
NaOH	0.1	10	0.010	5875.91	6.23
NaOH	0.1	15	0.086	51381.8	6.20
NaOH	0.1	20	0.321	183487.9	5.93

Table S1 Total charges and amounts of n-GaN losses in samples etched in various conditions.



Fig. S1 Observations of nanoporous structures of n-GaN after etching in (a) 0.25 M  $H_2SO_4$  at 15 V, (b) 1 M  $Na_2SO_4$  at 20 V, and (c) 0.1 M NaOH at 15 V



Fig. S2 SEM of samples etched in 0.1 M NaOH.



Fig. S3 EDS mapping of surface of sample etched in 0.25 M H<sub>2</sub>SO<sub>4</sub>.



Fig. S4 EDS mapping of surface of sample etched in 1 M Na<sub>2</sub>SO<sub>4</sub>.



Fig. S5 EDS mapping of surface of sample etched in 0.1 M NaOH.



Fig. S6 Voltammograms of n-GaN working electrodes in (a) 0.05 M  $H_2SO_4$ , (b) 0.1 M  $Na_2SO_4$  and (c) 0.1 M NaOH. Current values are normalized to 1 cm<sup>2</sup> of n-GaN sample.